

Large-Scale Synthesis of High-Quality Graphene Sheets by Improved Alternating Current Arc-discharge Method

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Table S1. BET surface area of samples synthesized under different buffer gases

Sample	AC-N1/H3	AC-N1/H2	AC-N1/H1	AC-N
BET surface area (m ² g ⁻¹)	119.50	125.39	143.72	144.72

Table S2. Elemental analysis of AC-N1/H2

	N	C	H
wt%	0.41	97.23	0.30
at%	0.64	93.34	3.51

Table S3. Elemental analysis of AC-N1/H2

Sample	N / at%	C / at%	O / at%
AC-N1/H1	0.78	95.88	3.34
AC-N1/H2	0.68	96.99	2.33
AC-N1/H3	0.61	96.62	2.77

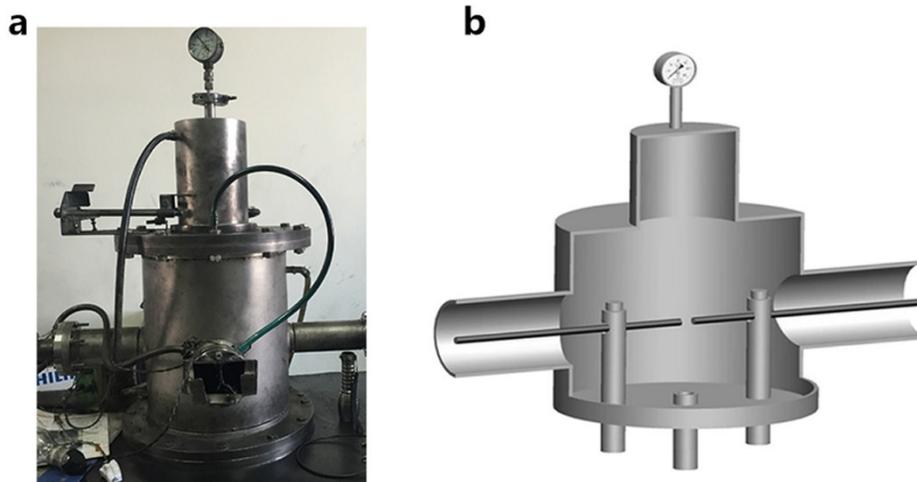


Fig.S1. (a) The photograph of arc furnace and (b) its schematic diagram

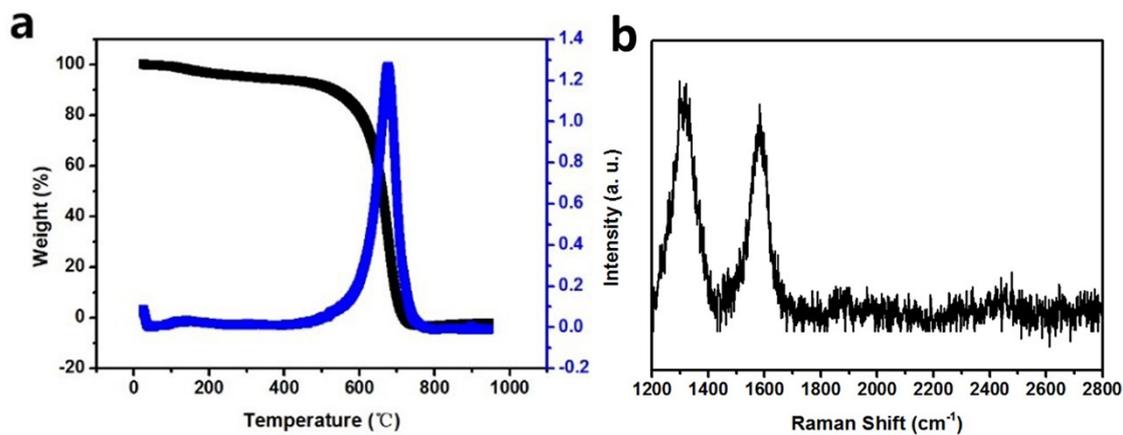
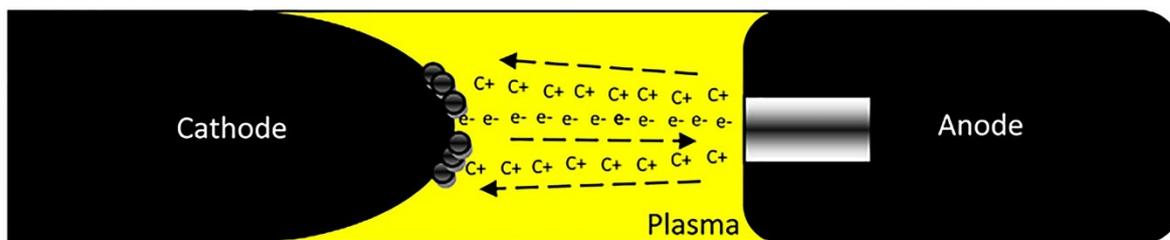
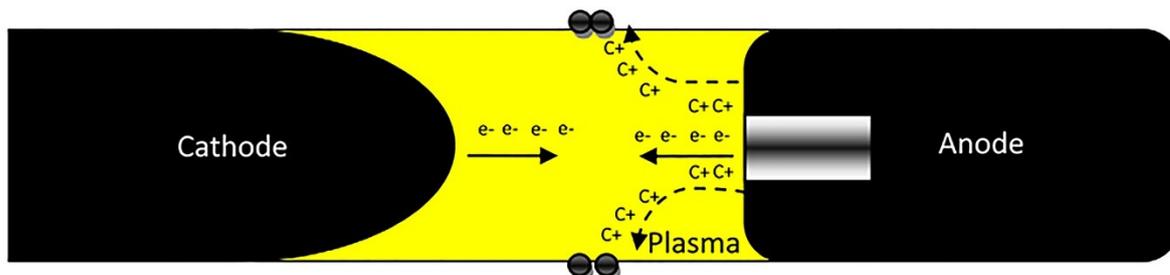


Fig. S2. (a) TGA curve of AC-N1/H2 after annealing at 400 °C for 1 h; (b) Raman spectra of AC-N.



(a) **DC Arc Discharge:** Continuous movement of ions and electrons in the plasma between the electrodes. Continuous Deposition obtained at Cathode



(b) **AC Arc Discharge:** The polarity of the electrodes changes after every cycle. Thus electrons are discharged from both side and results in C+ ions from anode flying away from the plasma. The deposition is obtained the reactor chamber walls. Lesser deposition obtained compared to DC and Pulsed Discharge.

Fig. S3. Schematics showing the mechanisms using different power supplies. (From ref. 16)

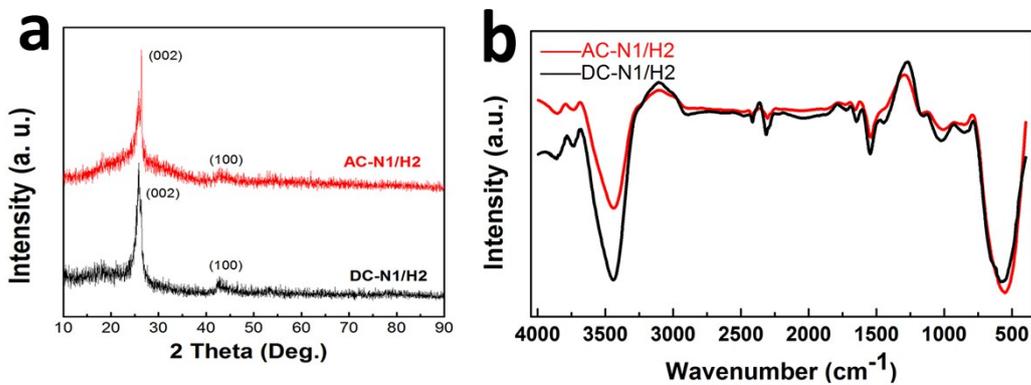


Fig. S4. (a) XRD pattern and (b) FT-IR spectra of AC-N1/H2 and DC-N1/H2.

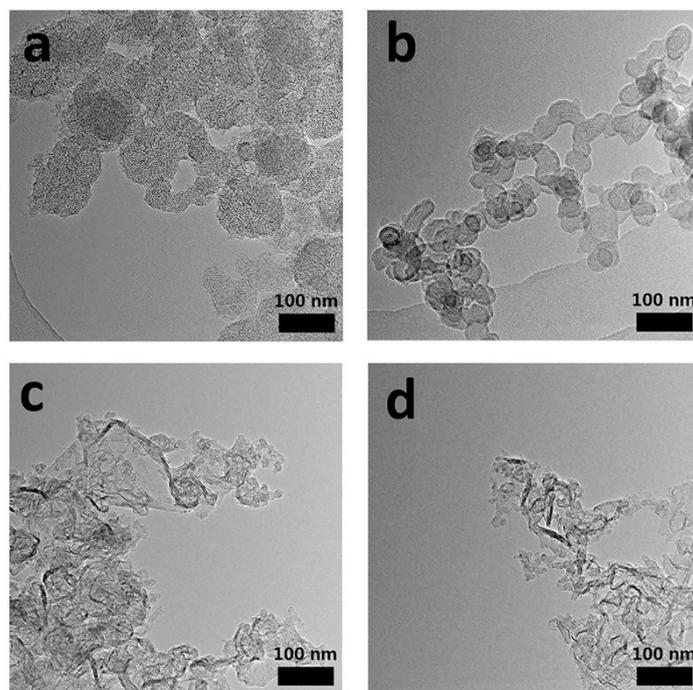


Fig. S5. TEM micrographs of (a) AC-N and (b) DC-N; (c) AC-H and (d) DC-H.

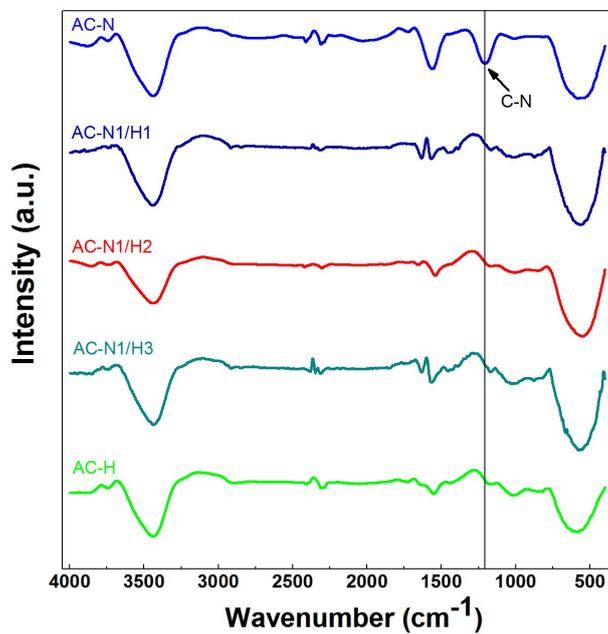


Fig. S6. FT-IR spectra of AC-N, AC-N1/H1, AC-N2/H2, AC-N1/H3 and AC-H.